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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Toshimitsu HIRAI

Group Art Unit: 2822

Application No.: 10/803,027

Examiner: M. WILCZEWSKI

Filed: March 18, 2004

Docket No.: 119152

For: METHOD OF FORMING THIN-FILM PATTERN, METHOD OF MANUFACTURING
DEVICE, ELECTROOPTICAL APPARATUS AND ELECTRONIC APPARATUS

AMENDMENT AND RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the March 27, 2006 Restriction Requirement, please consider the
following:

Amendments to the Claims as reflected in the listing of claims;

Remarks.